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(12) **United States Design Patent**
Teramura et al.

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(54) **CULTURE DEVICE**

(71) Applicant: **JNC CORPORATION**, Tokyo (JP)

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(73) Assignee: **JNC CORPORATION**, Tokyo (JP)

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(51) **LOC (12) Cl.** **24-02**

(52) **U.S. Cl.**
USPC **D24/224**

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USPC D24/216, 223–227, 229–232; D9/420,
D9/537, 545, 549, 700, 705, 706;
D3/203.1, 203.2; D10/81; D28/78
CPC .. B01L 3/0275; B01L 3/5085; B01L 3/50825;
C12M 23/10; C12M 23/12
See application file for complete search history.

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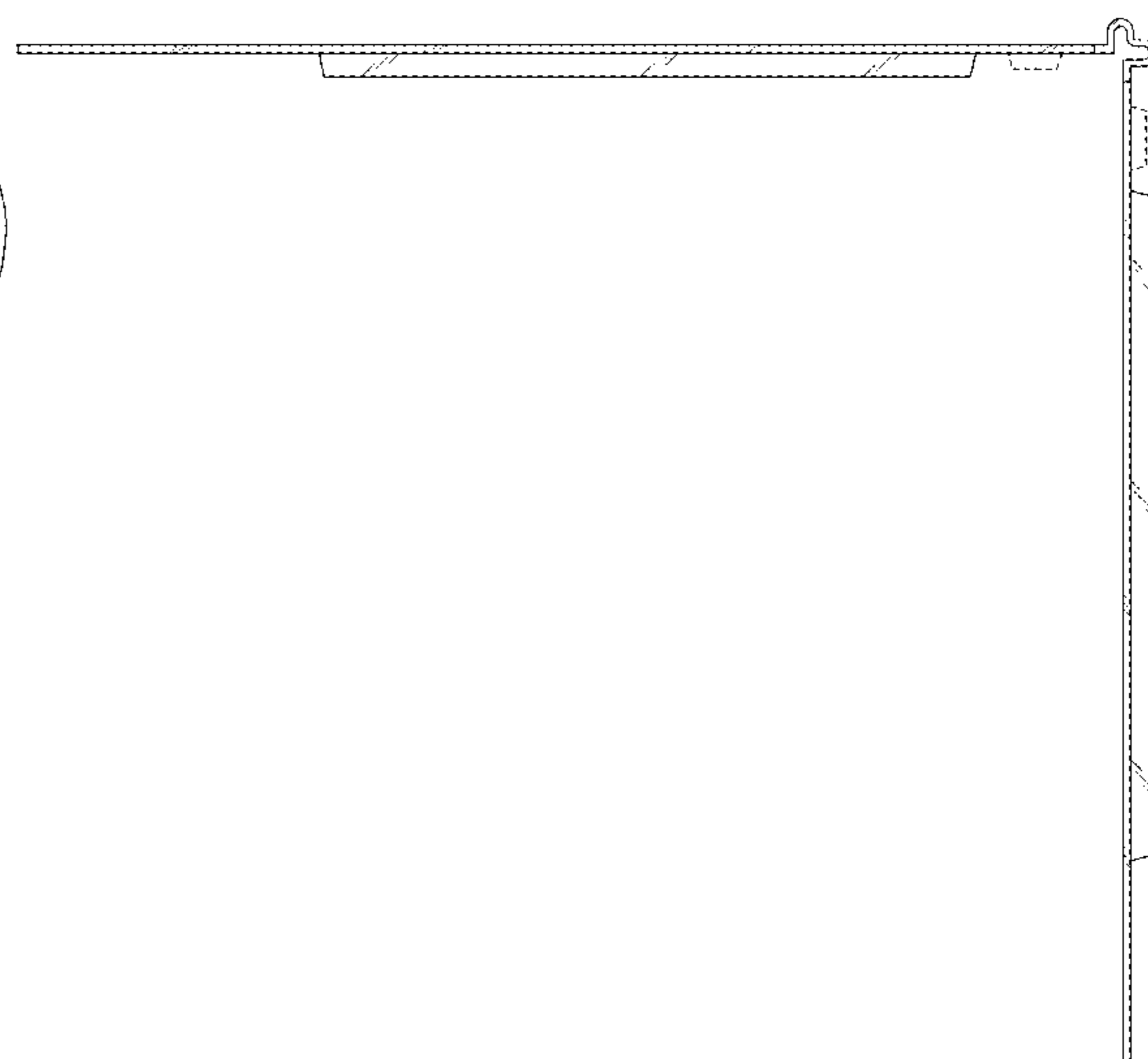
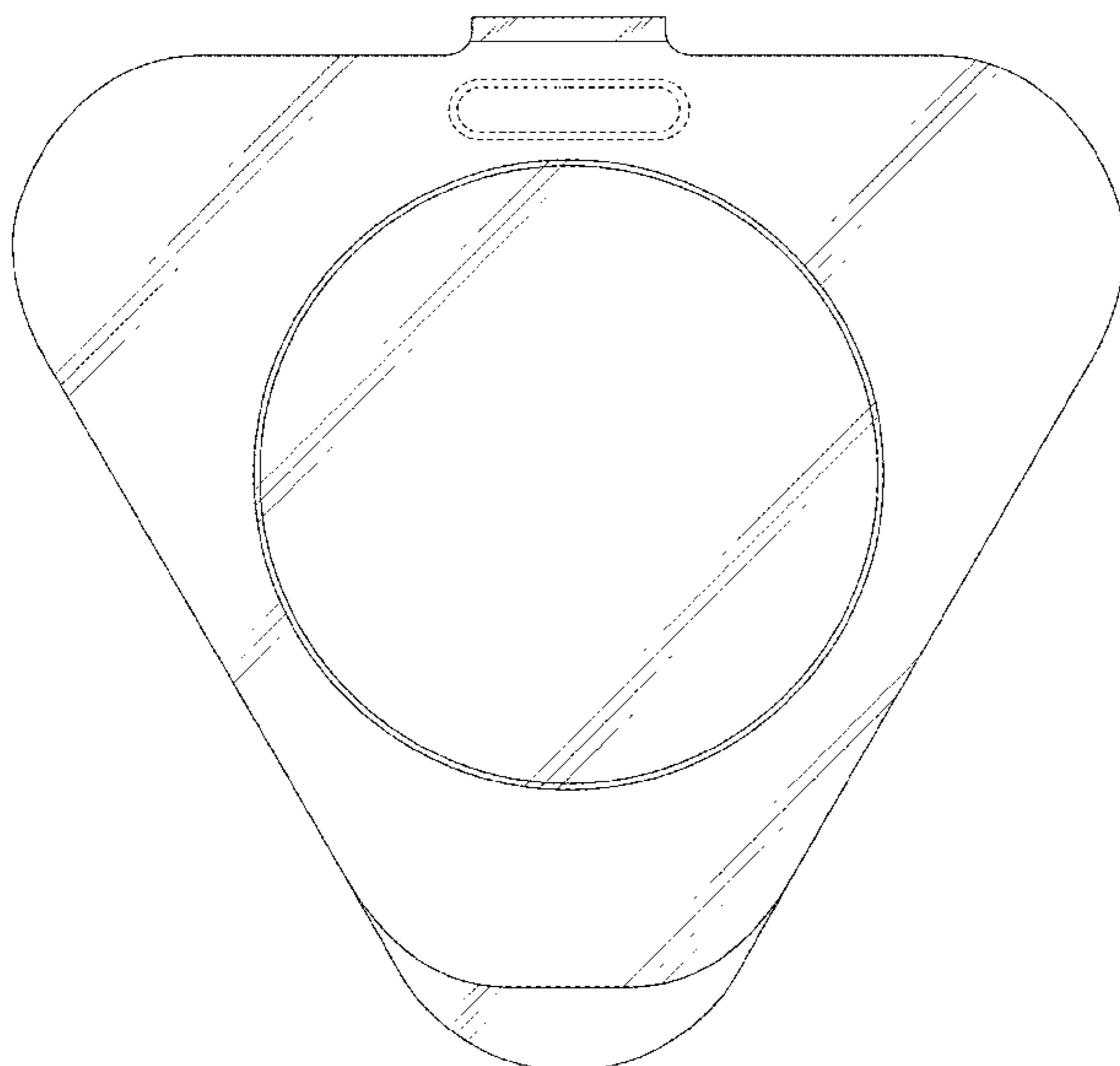
(57) **CLAIM**

The ornamental design for a culture device, as shown and described.

DESCRIPTION

FIG. 1 is a front elevational view of a culture device showing our new design;
 FIG. 2 is a rear elevational view thereof;
 FIG. 3 is a left side elevational view thereof;
 FIG. 4 is a right side elevational view thereof;
 FIG. 5 is a top plan elevational view thereof;
 FIG. 6 is a bottom elevational view thereof;
 FIG. 7 is a cross-sectional view thereof taken along line 7-7 of FIG. 1;
 FIG. 8 is a front elevational view thereof in an open position; and,
 FIG. 9 is a right side elevational view thereof in an open position.
 The broken lines in the drawings depict portions of the culture device that form no part of the claimed design.

1 Claim, 7 Drawing Sheets



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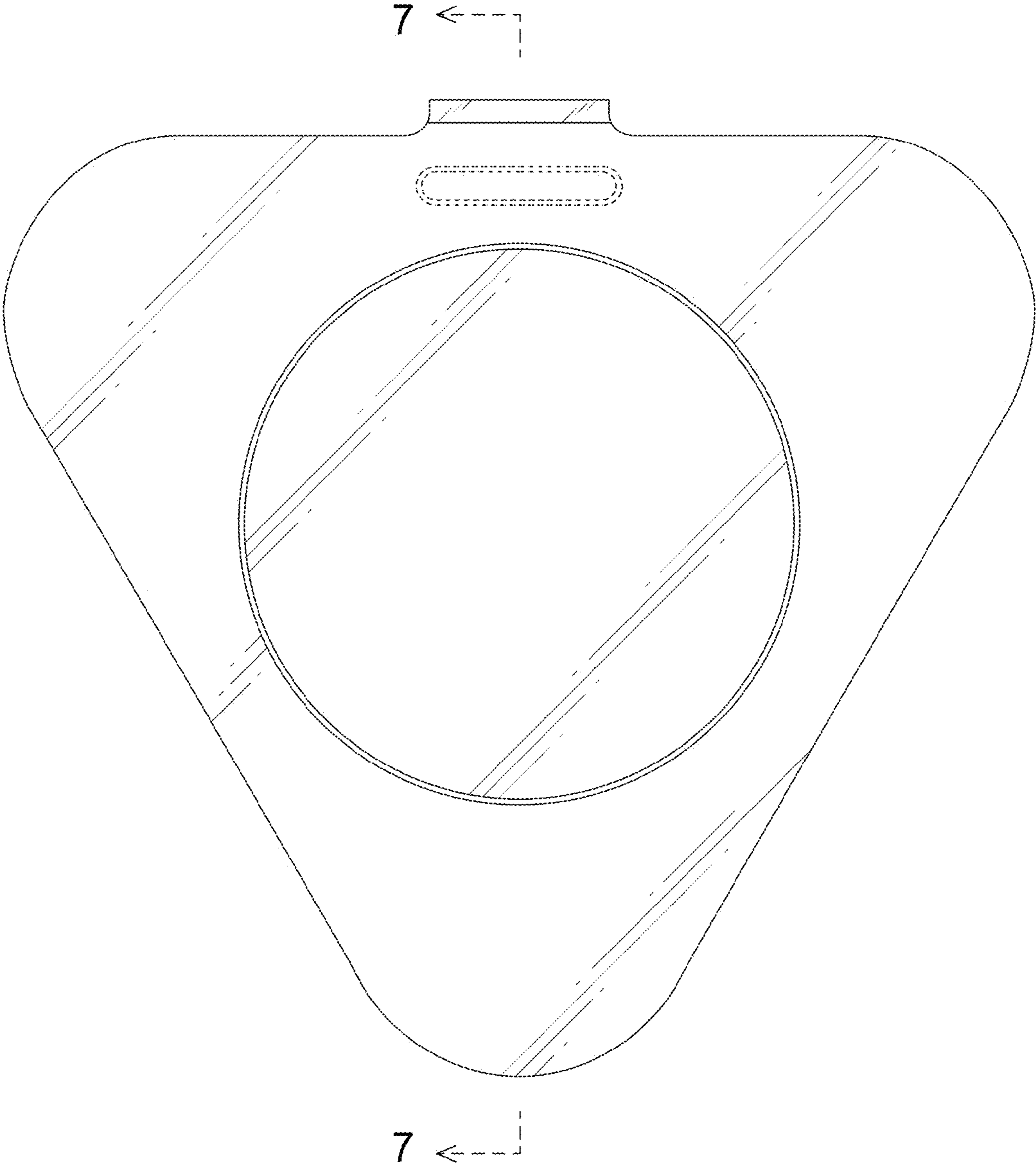


FIG. 1

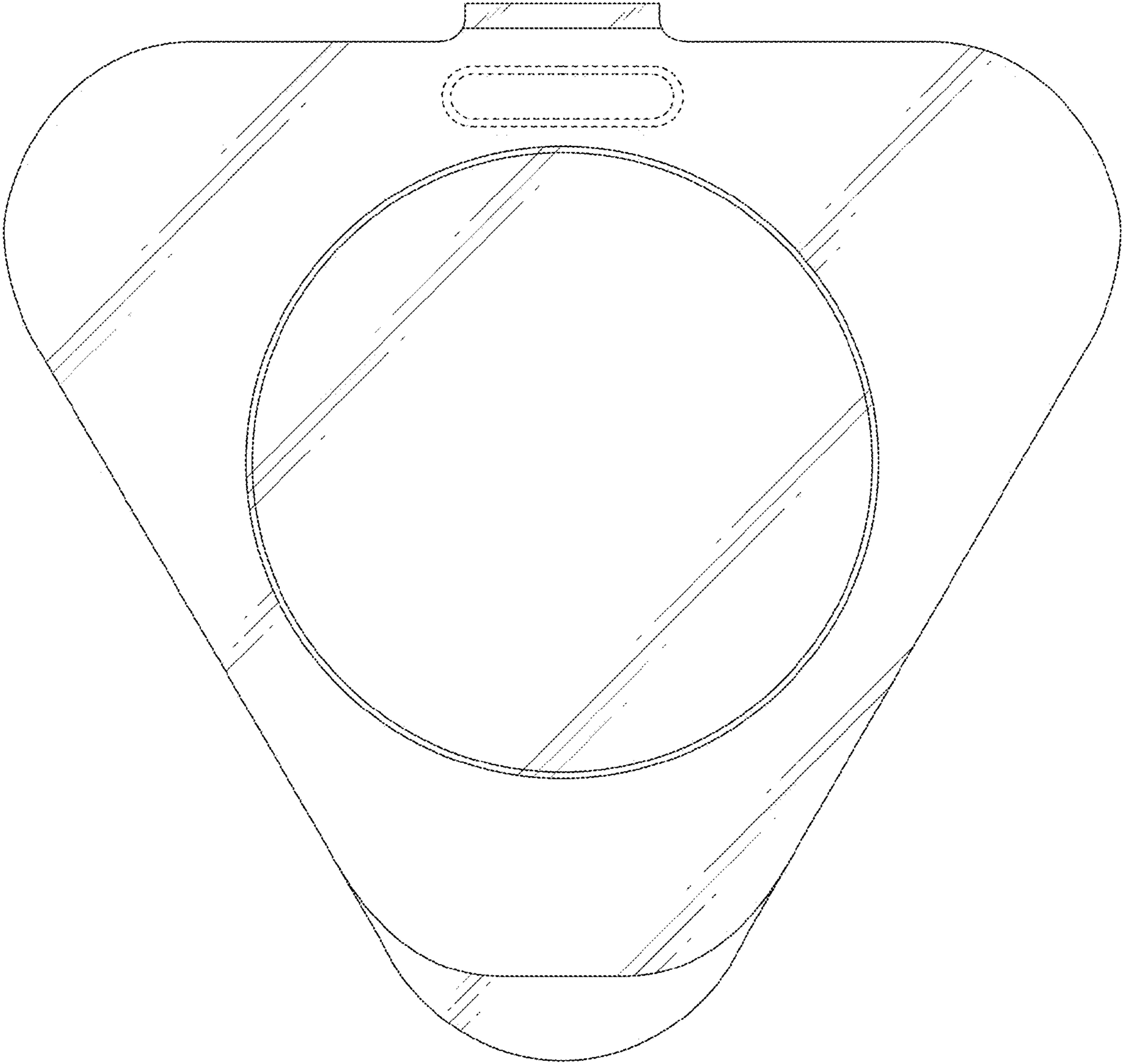


FIG.2

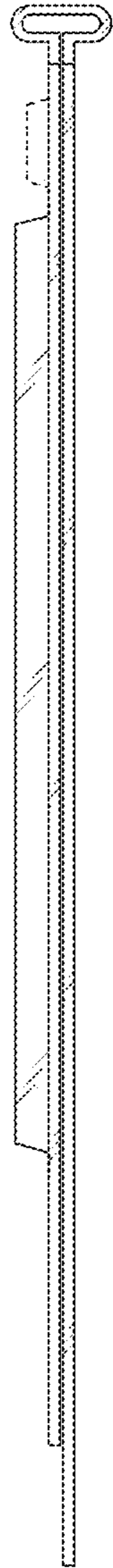


FIG.3

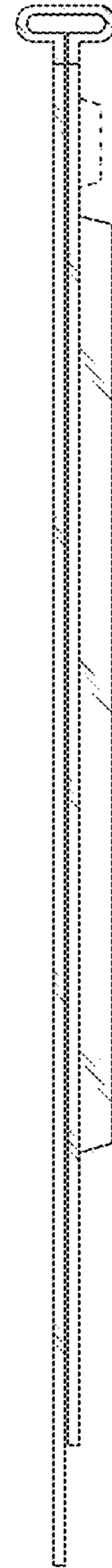


FIG.4

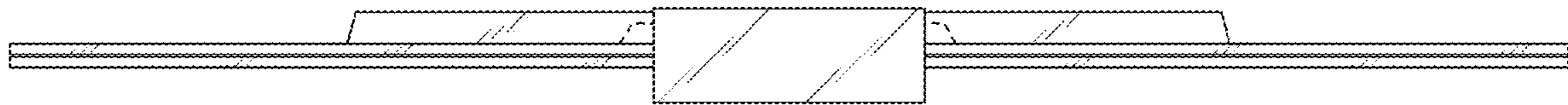


FIG.5

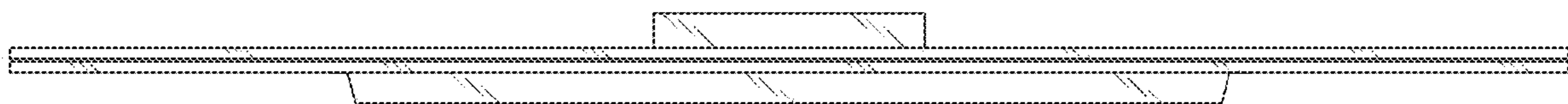


FIG.6

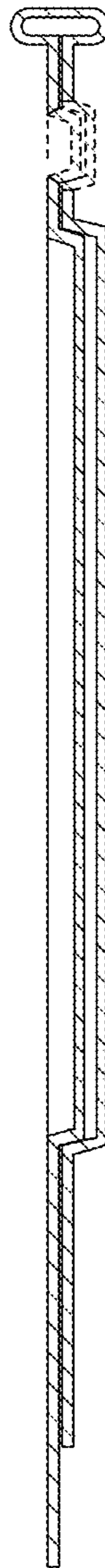


FIG.7

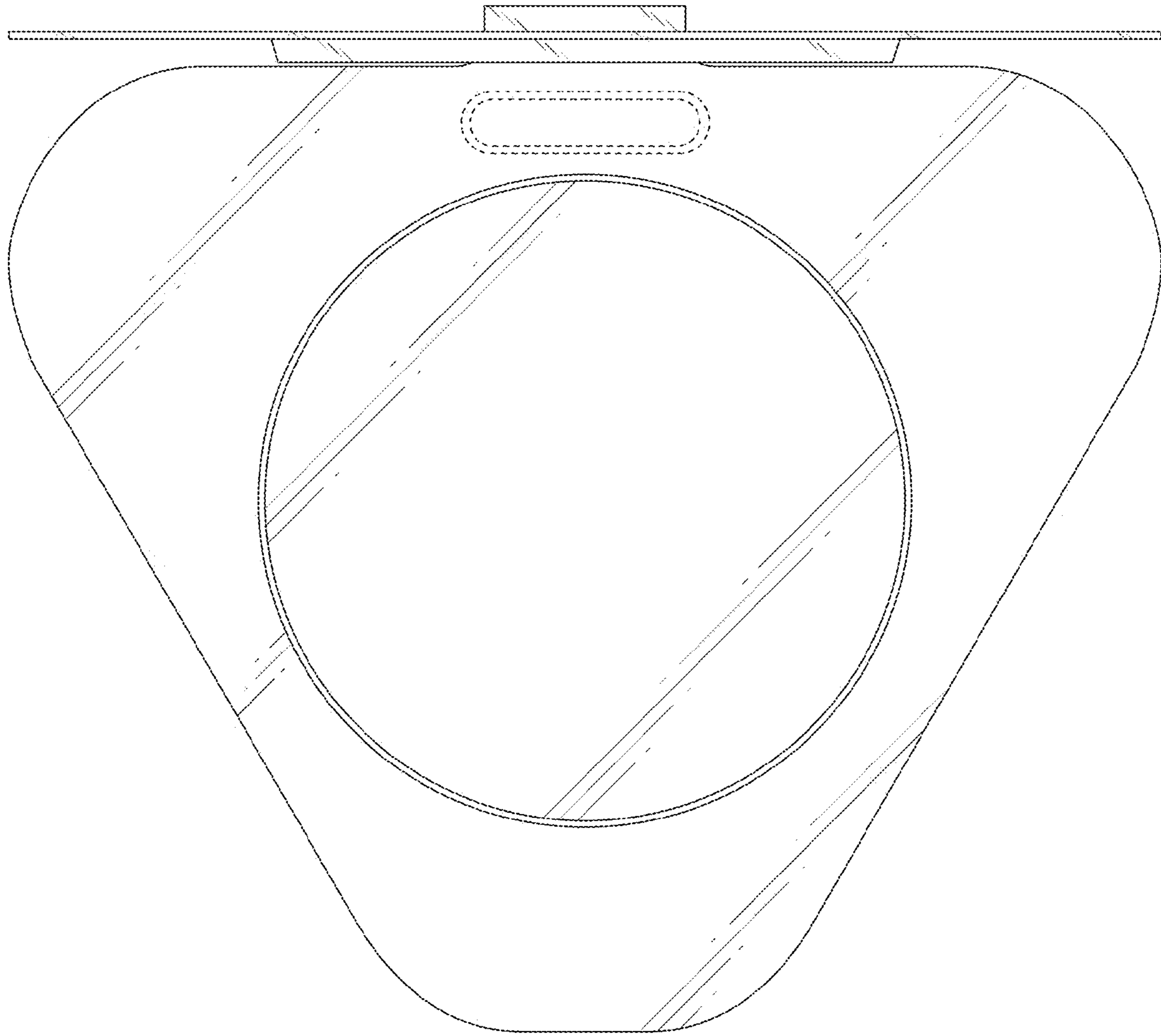


FIG.8

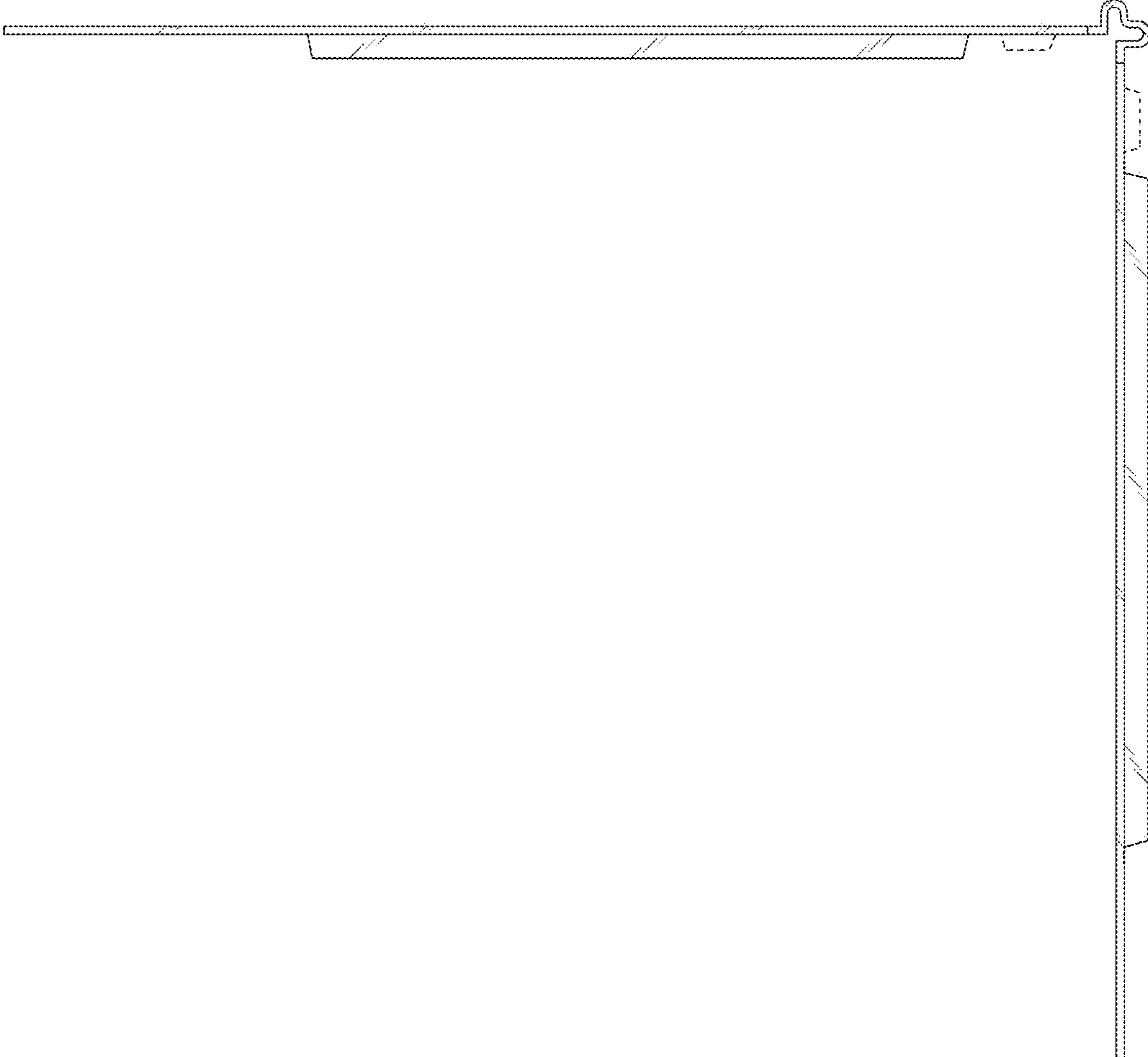


FIG.9